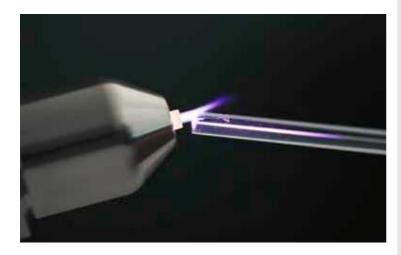


## kINPen®

atmospheric pressure discharge



## technical specification

Plasma as a cross-sectional technology in many industry branches, but also in research laboratories, is an indispensable tool in surface treatment. Plasma technology is used everywhere where quality, productivity, environmental sustainability, precision and flexibility is important.

Surfaces are cleaned, activated and decontaminated at atmospheric pressure with the handy kINPen®. The device is particularly used for surface treatment of temperature-sensitive materials as, for instance, plastics. In addition, kINPen® provides you an easy access to geometric challenging surfaces such as narrow clefts, capillaries or subtlest bores.

The kINPen® base model is argon-powered. The admixture of reducing or oxidizing gases can be done up to the percentage range. Furthermore, the device is convertible through the simple change of its electrode head to operate with molecular gases like air or nitrogen.

## kINPen® features

- compact and mobile
- easy handling
- wide application spectrum
  - o activation
  - o fine cleaning
  - o decontamination
- treatment of

general description

- o temperature-sensitive materials
- o sophisticated geometric shapes
- o hard-to-get-at locations
- precise and point-by-point operation
- powered by noble and molecular gases
- easy process integration

	source for surface treatment
dimensions handheld	180 mm, Ø 20 mm (1.50 m connector cable
weight handheld	170 g
protection category handheld	IP30
dimensions base unit	105 x 180 x 330 mm (H x W x D)
weight base unit	4 kg
protection category base unit	IP40
power supply	110 - 230 VAC, 50/60 Hz
power consumption	<50 W at 230 V, 50 Hz
transport and storage temperature	-40 °C - 70 °C
temperature rel. humidity	
temperature rel. humidity working conditions	-40 °C - 70 °C
	-40 °C - 70 °C 10 % - 100 % 15 °C - 40 °C
temperature rel. humidity  working conditions temperature	-40 °C - 70 °C 10 % - 100 %
temperature rel. humidity  working conditions temperature rel. humidity air pressure	-40 °C - 70 °C 10 % - 100 % 15 °C - 40 °C 15 % - 75 %
temperature rel. humidity  working conditions temperature rel. humidity air pressure	-40 °C - 70 °C 10 % - 100 % 15 °C - 40 °C 15 % - 75 %
temperature rel. humidity  working conditions temperature rel. humidity air pressure  source	-40 °C - 70 °C 10 % - 100 %  15 °C - 40 °C 15 % - 75 % 800 hPa - 1060 hPa  Argon* * other gases and mixtures on request
temperature rel. humidity  working conditions temperature rel. humidity air pressure  source process gases	-40 °C - 70 °C 10 % - 100 %  15 °C - 40 °C 15 % - 75 % 800 hPa - 1060 hPa  Argon* * other gases and mixtures on request 3 - 8 litre per minute*
temperature rel. humidity  working conditions temperature rel. humidity air pressure  source	-40 °C - 70 °C 10 % - 100 %  15 °C - 40 °C 15 % - 75 % 800 hPa - 1060 hPa  Argon* * other gases and mixtures on request
temperature rel. humidity  working conditions temperature rel. humidity air pressure  source process gases	-40 °C - 70 °C 10 % - 100 %  15 °C - 40 °C 15 % - 75 % 800 hPa - 1060 hPa  Argon* * other gases and mixtures on request 3 - 8 litre per minute*

line cord

kINPen® base unit incl. handheld electrode head (preinstalled)

compact atmospheric pressure plasma

